# Highly Efficient Semiconductor-Based Metasurface for Photoelectrochemical Water Splitting: Broadband Light Perfect Absorption with Dimensions Smaller than the Diffusion Length



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#### Abstract

In this paper, we demonstrate a highly efficient light trapping design that is made of a metal-oxide-semiconductor-semiconductor (nanograting/nanopatch) (MOSS<sub>g/p</sub>) four-layer design to absorb light in a broad wavelength regime in dimensions smaller than the hole diffusion length of the active layer. For this aim, we first adopt a modeling approach based on the transfer matrix method (TMM) to find out the absorption bandwidth (BW) limits of a simple hematite ( $\alpha$ -Fe<sub>2</sub>O<sub>3</sub>)-based metal-oxide-semiconductor (MOS) cavity design. Our modeling findings show that this design architecture can provide near-perfect absorption in shorter wavelengths. To extend the absorption toward longer wavelengths, a nanostructured semiconductor is placed on top of this MOS design. This nanostructure supports the Mie resonance and adds a new resonance in longer wavelengths without disrupting the lower wavelength absorption capability of MOS cavity. By this way, a polarization-insensitive absorption above 0.8 can be acquired up to  $\lambda$ =565 nm. Moreover, to have a better qualitative comparison, the water-splitting photocurrent of this design has been estimated. Our calculations show that a photocurrent as high as 10.6 mA cm<sup>-2</sup> can be achieved with this design that is quite close to the theoretical limit of 12.5 mA cm<sup>-2</sup> for hematite-based water-splitting photoanode. This paper proposes a design approach in which the superposition of cavity modes and Mie resonances can lead to a broadband, polarization-insensitive, and omnidirectional near-perfect light absorption in dimensions smaller than the carrier's diffusion length. This can be considered as a winning strategy to design highly efficient and ultrathin optoelectronic designs in a variety of applications including photoelectrochemical water splitting and photovoltaics.

Keywords Metamaterials  $\cdot$  Semiconductor metasurfaces  $\cdot$  Perfect absorber  $\cdot$  Plasmonics  $\cdot$  Photochemistry  $\cdot$  Light-driven water splitting

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## Introduction

The concept of metamaterials and metasurfaces has emerged as a promising route to engineer the light-matter interaction in nanostructure geometries [1–7]. Light confinement in subwavelength geometries has turned into one of the most intensively explored areas in recent years. These devices are ideally designed to perfectly absorb and harvest light in a narrow or broad frequency range [8-23]. These perfect metamaterial absorbers have a wide range of applications including sensing [24-26], filtering [27, 28], coherent emission [29-32], photovoltaics and thermal photovoltaics [33-38], photodetection [39–41], solar vapor generation [42], and photochemistry [43–45]. Among these applications, photochemistry and photoelectrochemical water splitting has become a promising technology to supply the future clean energy demand, and it is thought to be the "holy grail" of energy conversion and storage revolution. For this reason, many different semiconductors and design configurations have proposed to achieve the required 10% solar-to-hydrogen (STH) efficiency for commercialization of this technology in large-scale use [46–49]. The essential requirement for achieving this goal is to fully harvest the solar irradiation in a broad frequency range covering the visible (Vis) and near-infrared (NIR) regimes.

Among all different semiconductors, hematite ( $\alpha$ -Fe<sub>2</sub>O<sub>3</sub>) with a narrow optical band gap (1.9-2.1 eV) can reach to a maximum theoretical STH efficiency of 15% that corresponds to a photocurrent value of 12.5 mA cm<sup>-2</sup>. However, besides many attempts and modifications to improve this [50-52], the obtained STH efficiencies are still far from this limit in hematite-based photoanodes. The reason for that is the poor electrical properties of the  $\alpha$ -Fe<sub>2</sub>O<sub>3</sub> semiconductor. The hole diffusion length for this semiconductor is as short as 20 nm, while the penetration depth of light is a couple of times larger than this [52, 53]. Therefore, most of the light absorbed inside the bulk of the medium (> 20 nm away from the surface) cannot be utilized for the water oxidation process. In other words, the electron-hole pairs generated inside the bulk recombine before the holes reach to the semiconductorelectrolyte interface. Therefore, nanostructuring is crucial for making hematite photoanodes efficient. Hematite nanostructures, such as nanoparticles, nanowires, nanotubes, and nanocones, are examples of these trapping high surface area morphologies [54-66]. In these three-dimensional scaffolds, light would be trapped and wholly harvested, and the high surface area will increase the probability of hole participation in water oxidation reaction. However, at the meanwhile, many bulk and surface recombination pathways, stemming from the bulky nature of these 3D architectures, can limit the overall water-splitting efficiency of the cell. Moreover, thinning down these nanostructures to radii as small as 20 nm is a synthetic challenge. The synthesis of ultrathin nanosheets with lateral dimensions as thin as  $\sim 10$  nm could be an option to minimize the path length of the holes. However, these nanosheets have also high recombination pathways, and they are not able to harvest the light as efficiently as other 3D [67–71]. Therefore, to approach the maximum STH efficiency, the ideal case is to use a trapping mechanism to fully harvest the light in a thin hematite layer to keep the electron and hole transport path below their diffusion length.

One of the most studied strategies to harvest the light in  $\alpha$ -Fe<sub>2</sub>O<sub>3</sub> dimensions as thin as 20 nm is to integrate these ultrathin layers with impedance-matched trapping 3D photonic scaffold [72–74]. It was theoretically found that a 20-nm  $\alpha$ -Fe<sub>2</sub>O<sub>3</sub> on indium-doped tin oxide (ITO) nanocones can reach a maximum photocurrent value of 12.5 mA cm<sup>-2</sup> due to the formation of slow waves in gradual impedance matching the condition of nanocones [72]. This value has been calculated by assuming that all the holes will contribute in the watersplitting reaction. However, the drawback of this design is the fact that the real synthesis of these high aspect ratio ITO nanocones is not a simple task. Moreover, a portion of light will pass through the design (considering the fact that ITO is an optically transparent medium and hematite is ultrathin) without getting absorbed by the  $\alpha$ -Fe<sub>2</sub>O<sub>3</sub> in which this deficiency can be quite significant in shorter nanocones. This was improved in later studies, where the authors used a back metallic reflector on the 3D scaffold design [73, 74]. They coated Al<sub>2</sub>O<sub>3</sub> 3D nanocone substrate with a three-layer design made of Ti/Pt-FTO- $\alpha$ -Fe<sub>2</sub>O<sub>3</sub> and experimentally demonstrated a photocurrent as high as 3.05 mA cm<sup>-2</sup> at 1.23 V vs RHE. As can be clearly seen, this value is well below the theoretical limit of 12.5 mA  $cm^{-2}$ , while the structure is supposed to perfectly harvest the light. The reason is the high lossy nature of metals (Ti and Pt) compared to low loss  $\alpha$ -Fe<sub>2</sub>O<sub>3</sub>. In a nanocone design, light is strongly confined between nanocones, and both metal and semiconductor layers have absorption coefficient to absorb this light. However, metals have much larger extinction compared to hematite, and therefore, most of the light is dissipated in the metal layer, and  $\alpha$ -Fe<sub>2</sub>O<sub>3</sub> cannot fully utilize the incoming broadband solar irradiation. Therefore, it would be better to provide this trapping mechanism in a planar configuration and concentrate the light absorption in the vicinity of the semiconductor layer. The excitation of surface plasmon resonances (SPRs) in noble metal nanostructures is one of these ways [75–79]. The use of gold nanopillars and nanoholes has been proposed to enhance the water-splitting efficiency of the hematite layer [77]. However, a part of the diffracted wave from these plasmonic designs will be harvested by the gold layer that restricts achieving maximum light absorption by the hematite layer. Previously, the use of a simple perfect mirror-semiconductor configuration was proposed by authors where this multilayer mirror provided light perfect absorption in a broad frequency range in the hematite layer [80]. Putting this planar multilayer structure in a V-shaped cell leads to a photocurrent value of 4 mA  $cm^{-2}$  in a design made of 26-nm-thick Ti-doped  $\alpha$ -Fe<sub>2</sub>O<sub>3</sub> films. Besides all these ideas, the utilization of Mie resonances in a hematite nanobeam was demonstrated as an efficient photoanode in light-driven water-splitting cell [81].

In this work, we propose an elegant water-splitting photoanode design comprising metal-oxide-semiconductorsemiconductor (nanograting/nanopatch) (MOSS<sub>g/p</sub>) as a highly efficient trapping configuration to harvest the light in a broad frequency range while keeping the active layer dimensions much smaller than the incident light wavelength. In this architecture, the metal layer is an optically thick aluminum (Al) mirror, the oxide layer is an ultrathin ITO layer, the planar semiconductor layer is a 16-nm-thick  $\alpha$ -Fe<sub>2</sub>O<sub>3</sub> layer, and the top nanostructured semiconductor is made of ultrathin cadmium sulfide (CdS). Here, the absorption of the light in shorter wavelengths is supported by the efficient coupling of the incident light into metal-oxide-semiconductor (MOS) cavity modes, while the longer wavelengths are harvested by the excitation of Mie resonances supported by CdS grating/patch. Therefore, by the superposition of these two responses, an efficient light harvesting can be achieved with an absorption above 0.8 in most of the spectral region above the optical band gap of hematite. The absorption of the light in dimensions below the diffusion length of  $\alpha$ -Fe<sub>2</sub>O<sub>3</sub> will increase the collection probability of the photogenerated carriers. Moreover, the proper band alignment between CdS and  $\alpha$ -Fe<sub>2</sub>O<sub>3</sub> will facilitate charge separation and reduce their recombination probability, and this in turn will maximize hole participation in a water-splitting reaction. Our theoretical calculations prove that the use of this semiconductor-based metamaterial can provide a photocurrent as high as  $10.7 \text{ mA cm}^{-2}$  and that is quite close to the maximum theoretical value. Similar to other theoretical studies, this value has been obtained by assuming that all of the generated carriers are collected due to the fact that the proposed design has dimensions smaller than the diffusion length of  $\alpha$ -Fe<sub>2</sub>O<sub>3</sub> and the existence of an  $\alpha$ -Fe<sub>2</sub>O<sub>3</sub>-CdS interface will further enhance the carrier separation probability. Our simulations also demonstrate that the proposed nanopatch design has absolute polarization insensitivity and good angular response and these are important for practical applications. Furthermore, compared to other trapping schemes, this structure has a very simple design configuration and can be easily scaled to large scales using common fabrication tools such as nanoimprint lithography. This study shows that a proper ultrathin planar and large-scale compatible design configuration can offer excellent optical and electrical properties in which a highly efficient photoelectrochemical water-splitting cell can be made using common and highly repeatable nanofabrication technologies.

## **Results and Discussion**

One of the most intensively explored semiconductor-based metamaterial designs is the metal-semiconductor (MS) configuration. The strong interface effects, induced by a bottom mirror, can provide light nearly perfect absorption in this design. In this configuration, the right choice of semiconductor geometries can significantly enhance the light-matter interaction [82–87]. However, this configuration can enhance light absorption to some extent. In the other words, this design has its own limit. To scrutinize the limits of this semiconductorbased MS metamaterial structure, we have adopted a modeling approach based on the transfer matrix method (TMM) to find the ideal condition for light perfect absorption in a visible (Vis) portion of the solar spectrum. The studied design architecture is shown in Fig. 1a. In this model, the bottom metal is chosen as highly reflecting silver (Ag) metal [88]. Afterward, the ideal real and imaginary parts of permittivity have been extracted for four different semiconductor thicknesses of  $D_{S}=5$ , 15, 25, and 35 nm. For this aim, the reflection of the design is calculated using TMM. In this modeling, we assume that the MS structure is bounded with a material of  $\varepsilon_A$  which is air. For transverse magnetic (TM) polarized light, taking the H<sub>v</sub> as [89]:

$$H_{y}(z) = \begin{cases} A_{i}e^{ik_{A}(z-D_{S})} + A_{r}e^{-ik_{A}(z-D_{S})}, \ z > D_{S} \\ S_{11}e^{ik_{S}z} + S_{12}e^{-ik_{S}z}, \ 0 < z < D_{S} \\ M_{21}e^{ik_{M}z} + M_{22}e^{-ik_{M}z}, \ -D_{M} < z < 0 \end{cases}$$
(1)

and applying the appropriate boundary conditions, the reflection of the incident light from the structure can be obtained as

$$R = |F_{12}/F_{11}|^2. \text{ Here, } F = \begin{bmatrix} F_{11} \\ F_{12} \end{bmatrix} = a^{-1}s_{11}s_{12}^{-1}m_{21}m_{22}^{-1} \text{ where:}$$

$$a = \begin{bmatrix} 1 & 1\\ ik_A/\varepsilon_A & -ik_A/\varepsilon_A \end{bmatrix},$$
 (2a)

$$s_{11} = \begin{bmatrix} 1 & 1 \\ ik_S/\varepsilon_S & -ik_S/\varepsilon_S \end{bmatrix}, s_{12}$$
$$= \begin{bmatrix} e^{ik_S D_S} & e^{-ik_S D_S} \\ ik_S e^{ik_S D_S}/\varepsilon_S & -ik_S e^{-ik_S D_S}/\varepsilon_S \end{bmatrix},$$
(2b)

$$m_{21} = \begin{bmatrix} 1 & 1 \\ ik_M/\varepsilon_M & -ik_M/\varepsilon_M \end{bmatrix}, m_{22}$$
$$= \begin{bmatrix} e^{ik_M D_M} & e^{-ik_M D_M} \\ ik_M e^{ik_M D_M}/\varepsilon_M & -ik_M e^{-ik_M D_M}/\varepsilon_M \end{bmatrix},$$
(2c)

and  $k_{i=(A,S,M)} = \sqrt{\varepsilon_i \omega^2 / c^2 - k_x^2}$  in which c is the speed of light,  $D_S$  is the semiconductor layer thickness, and  $D_M$  is the bottom metal layer thickness. Using the above-mentioned formulations, the real and imaginary parts of ideal material permittivity have been calculated. These regions have been exhibited as highlighted regions. It should be mentioned that the ideal region is defined as the range of permittivity values in which an absorption above 0.8 (reflection below 0.2) can be attained. Therefore, if the real and imaginary parts of the permittivity of a semiconductor are located inside these regions, we can say that the MS design has harvested above 80% of the incident light in that specific wavelength value. The matching of these ideal regions has been compared with those of the permittivity data of three different semiconductors, including germanium (Ge, as a narrow-band-gap semiconductor), perovskite (PVSK, as an organic narrow-band-gap semiconductor), and Fe<sub>2</sub>O<sub>3</sub> (hematite, as a narrow-band-gap metal oxide). As shown in Fig. 1b, the real part of permittivity stays out of the ideal region for all three types of semiconductors and that proves the poor absorption characteristic of the MS structure in such thin layers. As we go toward larger thicknesses, the ideal region moves toward smaller positive values, and, therefore, matching can be met in a narrow frequency range. As shown in Fig. 1c, this matching is obtained in a range of 600-



Fig. 1 (a) Schematic representation of the studied MS design to find the ideal condition for light perfect absorption. The comparison between the ideal region and permittivity data of different semiconductors for four different  $D_S$  values of (b) 5, (c) 15, (d) 25, and (d) 35 nm

700 nm for Ge (in agreement with previous studies [85–87]), while the matching is satisfied in wavelength values below 500 nm for PVSK and Fe<sub>2</sub>O<sub>3</sub> [82]. Increasing  $D_S$  to 25 nm, Ge loses its matching, while Fe<sub>2</sub>O<sub>3</sub> absorption upper edge experiences a red shift (see Fig. 1d). The thicker layers, however, make the ideal region narrower, and the matching is lost for Ge and Fe<sub>2</sub>O<sub>3</sub>. Therefore, the optimal thickness for Ge is 15 nm, while the optimal condition for  $Fe_2O_3$  is attained in a thickness of 25 nm where an absorption above 0.8 can be achieved from 400 to 525 nm. For the case of PVSK, the best results are recorded in the semiconductor layer thickness of 35 nm in which the absorption bandwidth (BW) can cover almost the whole Vis regime (400-650 nm). Therefore, in an MS configuration, every material has its own ideal semiconductor layer thickness. However, this absorption response is limited to a specific spectral range, and further improvement can be obtained by tailoring the design architecture.

Gaining an insight on the limits of this configuration, in the next step, numerical simulations are conducted to find the optimum design geometries for a highly efficient  $Fe_2O_3$ -based watersplitting photoanode. For this goal, a commercial finite-difference time-domain (FDTD) software package (Lumerical FDTD Solutions) [90] is exploited to numerically simulate the design optical performance. The structure is excited with a broad-band plane wave spanning from 400 to 750 nm in our desired polarization and incidence angles. The simulation is performed in two-dimensional (2D) mode. The boundary conditions (BCs) in the *x* and *y* directions are chosen as periodic. The bottom and top BCs are set as a perfectly matched layer (PML). Since the bottom layer is an optically thick mirror with almost no transmission, it

can be safely said that there is zero transmittance in this device. Therefore, the absorption spectra can be calculated directly from the reflection spectra using the following formula A = 1 - R. The reflection monitor is placed on top of the incident source excitation plane to only collect the reflected wave. Since this structure is going to be used in a water-splitting setup, we need to consider the electrical properties of the design as well. Due to the large energy level difference between the Fermi level of Ag and conduction band of Fe<sub>2</sub>O<sub>3</sub>, this structure may suffer from poor charge collection efficiency. Therefore, a conductive transparent layer should be embedded between these two layers to facilitate electron transfer. Optical transparent conductive indium-doped tin oxide (ITO) is an excellent option that can provide the proper conditions for the optical and electrical performance of the design. To gain insight on the impact of the ITO layer in the absorption functionality of the system, the response of the MS structure is compared with that of the metal-oxidesemiconductor (MOS) cavity where the oxide is the ITO layer with different thicknesses. Figure 2a shows the absorption spectra of the MS structure for different semiconductor thicknesses  $(D_{\rm S})$  spanning from 5 to 25 nm with a step size of 5 nm. The same sweep is performed for an MOS junction with different oxide thicknesses of 5, 10, 15, and 20 nm, as shown in Fig. 2b-e. To have a better qualitative comparison, the average visible light absorption (400-700 nm) has been calculated using the following formula:

Average Absorption = 
$$\frac{\int_{400 \ nm}^{700 \ nm} \alpha(\lambda) \ \Delta\lambda}{\int_{400 \ nm}^{700 \ nm} \ \Delta\lambda}$$
(3)



Fig. 2 The absorption spectra for (a) MS design with different semiconductor layer thicknesses. The absorption spectra for MOS designs with different semiconductor layer thicknesses for oxide layer

thicknesses of (b) 5, (c) 10, (d) 15, and (e) 20 nm. (f) The calculated average absorption for different MOS designs

where  $\alpha$  is absorption coefficient and  $\lambda$  is the incident light wavelength. Looking at Fig. 2f, it can be seen that the highest average absorption for an MS structure is attained at the  $D_S$  value of 25 nm that is in line with our findings from previous section modeling. In general, by moving to an MOS configuration, the absorption decreases compared to that of an MS junction. However, in the  $D_S = 20$  nm, the oxide thickness of 5 nm leads to a maximum average absorption of 0.53 which is close to that of the maximum amount for an MS junction. Therefore, by embedding an ultrathin ITO layer, not only the optical absorption stays high but also the electrical charge separation for photoinduced electrons will be facilitated compared to an MS design. In this optimal condition, above 0.8 absorption is acquired from 400 to 525 nm, which is in agreement with our expectations from the limit of this design. Considering the optical band gap of Fe<sub>2</sub>O<sub>3</sub> which extends up to 590 nm, the portion of the light in longer visible range cannot be harvested efficiently, and thus the photoactivity of this photoanode is restricted in this planar configuration. Thus, we need to exploit a new design configuration to be able to extend the absorption edge toward the absorption edge of Fe<sub>2</sub>O<sub>3</sub>. This could be attained by adding Mie resonances into the design. It is in this way that the absorption in shorter wavelengths will be supported by the cavity design and the longer  $\lambda$ s will be harvested by the help of Mie resonances. To achieve this goal, we proposed the design configuration as shown in Fig. 3a. As shown in this panel, cadmium sulfide (CdS) grating has been added into the top of the MOS junction. CdS is a large band gap semiconductor, and it is expected that it would not hamper the cavity response of the underlying MOS design. Another reason why we used this material as a grating layer is its excellent band alignment matching with Fe<sub>2</sub>O<sub>3</sub>, in which photoinduced electron-hole pairs inside the hematite layer will be spatially isolated by CdS and consequently the recombination probability of these carriers will significantly decrease [91, 92]. The geometries of each layer have been exhibited in the same panel. In this architecture, P is the periodicity of the grating, W is the width of the grating which is an  $\alpha$  portion of P, D<sub>G</sub> is the grating thickness, and  $D_S$  is Fe<sub>2</sub>O<sub>3</sub> layer thickness. The ITO layer is fixed at an optimal thickness of 5 nm. To begin with, we need to know the optimum thickness of the grating layer. For this, a sweep is conducted on the  $D_G$  values from 5 to 25 nm with a step size of 5 nm. These sweeps are repeated for different semiconductor layer thicknesses of 10, 15, 20, and 25 nm. In this set of simulations, the periodicity is fixed at 250 nm, and  $\alpha$  is set at 0.5. As shown in Fig. 3b-e, a new peak is added to the response of an MOS design that originated from the existence of CdS grating. This peak gets a slight redshift as the  $D_G$  increases. Moreover, as already explained, independent from the grating geometries, the short wavelength absorption response is only defined with the MOS cavity dimensions. A proper design should keep the absorption response above 0.8 in a wide frequency range, and this can be obtained by adjusting the spectral position of the Mie resonance related peak in the vicinity of the absorption upper edge of MOS design. This has been achieved in the design geometries of  $D_s$ = 15 nm and  $D_G$ = 25 nm in which absorption has been retained above 0.8 up to 550 nm.

Based on the guided-mode resonance theory, the spectral position of these Mie resonances are not only tuned with core layer thickness, but also the spacing between gratings can alter this resonance [81]. The optimal mode coupling conditions is



Fig. 3 (a) Schematic representation of  $MOSS_{g/p}$  design showing its different layers and geometries. The absorption spectra with different  $D_G$  values for four different  $D_S$  values of (b) 10, (c) 15, (d) 20, and (e) 25 nm

achieved when the momentum matching condition (G = k) is satisfied. In this formula,  $k = 2\pi n_{\text{eff}}/\lambda$  where  $n_{\text{eff}}$  is the effective mode index for the quasi-guided mode supported by the design. To gain an understanding on the physics behind these absorption peaks, we have plotted the ratio of the absorbed power in this grating design to that of the best planar design as a function of *G*. To find the total absorbed power inside the semiconductor layer, we have employed the following formula:

$$A(\lambda) = \frac{1}{P_{incident}} \int_{400 \ nm}^{700 \ nm} 0.5 \ \omega \ imag(\varepsilon_{Fe2O3}) |E(x, z, \lambda)|^2 dx \ dz$$

$$\tag{4}$$

To have a better visualization, the bottom limit of this counter plot is set at one. As Fig. 4a illustrates, increasing the periodicity (reducing the G parameter) of the structure increases the strength of the ratio where an enhancement as high as 3.5 can be achieved compared to the optimal planar design. Moreover, together with this enhancement, a redshift is experienced as we increase the spacing of the grating. Considering the previous results, although the enhancement ratio increases with increasing the periodicity, the absolute absorption of the design exponentially drops in a longer wavelength. Therefore, we also need to examine the absolute absorption values of the grating structure as the function of P. This data has been plotted in Fig. 4b. As this graph clearly illustrates, as we go toward larger grating spacing, a dip starts to appear in wavelengths between 520 and 580 nm. In fact, increasing the periodicity decouples the absorption response due to cavity modes and those due to Mie resonances. Thus, in our case, a moderate P

will lead to a maximum absorption response. To finalize our simulations, we pick three periodicities of 250, 290, and 330 nm and span  $\alpha$  (corresponding to the width of grating) from 0.3 to 0.7. According to the results presented in Fig. 4ce, the optimal condition is realized when the periodicity is set at 290 nm, and  $\alpha$  is 0.4. In this condition, the absorption BW (defined as the spectrum with absorption above 0.8) is expanded from 400 to 565 nm. To the best of our knowledge, this is the broadest absorption BW reported for a planar sub-wavelength hematite-based photoanode.

To have a solid understanding on the nature of these resonance modes, we have simulated the electric field (E-field) and magnetic field (H-field) distributions within the cavity in two wavelengths. One is located at 450 nm that corresponds to the place that we have near unity flat absorption and the other is chosen as 555 nm that is the spectral position of the second resonance peak. Figures 5a depicts the E-field and H-field distributions at  $\lambda = 450$  nm. As this figure implies, the Efield is mainly concentrated in the walls of CdS grating, and magnetic field has been dominantly focused beneath of the grating. The formation of the standing wave just below the grating has localized the incoming incident light within the cavity where this light is mainly harvested with the Fe<sub>2</sub>O<sub>3</sub> semiconductor layer due to its higher extinction coefficient. However, these profiles are significantly different for the second resonance peak. In this case, as illustrated in Fig. 5b, the E-field is tightly confined within the low refractive index ITO layer which is sandwiched with two high-index mediums. This distribution again confirms our above explanations that second resonance mode is originated from the coupling of



Fig. 4 (a) The ratio of the absorbed power in the grating design to that of the best planar design as a function of G. (b) The absorbed power in the grating design to that of the best planar design as a function of G. (b) The absorbed power in the grating design as a function of  $\alpha$  for different P values of (c) 250, (d) 290, and (e) 330 nm

incident light into guided mode resonances, supported with the cavity design. Moreover, H-field, in this case, is dominantly localized between the nanogratings rather than being confined underneath the grating.

Taking all the above-mentioned results into consideration, the proposed design architecture can efficiently harvest the light in a broad frequency range through the superposition of MOS cavity modes and grating based-guided mode resonances. However, the only drawback with this design is its polarization sensitivity of the grating. As we move from TM polarization toward transverse electric (TE) polarization, the excitation of guided mode resonances is hampered. To mitigate this drawback, we replaced the grating with a square nanopatch. The same optimization process is applied to this design to maximize its absorption BW. The optimal geometries for this case were found as  $D_O=5$  nm,  $D_S=16$  nm,  $D_G=25$  nm, P=300 nm, and  $\alpha = 0.55$ . The optimized results for all three cases of planar, grating, and patch have been plotted in Fig. 6b. As this figure clearly shows, relatively similar responses have been attained for both grating and patch designs. Figure 6 c–d plot the absorption spectra of grating and patch designs, respectively. The bottom limit of the contour plot is set at 0.8 to provide a better visualization of the narrowing of the absorption BW. According to these plots, for the grating-based metasurface design, changing the polarization angle from 0° to 90° imposes a blue shift in the upper absorption



Fig. 5 The E-field and H-field distribution for the proposed metasurface design in two different wavelengths of (a) 450 and (b) 555 nm



**Fig. 6 (a)** The schematic representation of the proposed metasurface design with a nanopatch top layer. **(b)** The comparison of the absorption spectra for three different design architectures. The absorption spectra of the **(c)** grating and **(d)** patch as a function of the polarization angle. **(e)** The absorption profile across the design in two different wavelengths of 450 and 555 nm. **(f)** The band alignment for

edge from 565 to 500 nm. Because incoming solar irradiation is an unpolarized light, this could limit the practical use of this structure for large-scale applications. Looking at polarization dependency of absorption profile for patch design, we can see that an absolute polarization-insensitive design has been obtained in this case. The absorption profile in a view plane cutting through the middle of the patch has been calculated using Eq. 4 and has been plotted in Fig. 6e. As this figure clearly implies, most of the light is harvested inside the Fe<sub>2</sub>O<sub>3</sub> layer. In the shorter wavelength regime, a negligible part of incident power is harvested inside the CdS layer, and in the upper band Ag mirror, it has a weak absorbing feature. Moreover, the absorption in  $\lambda = 450$  nm is mainly in the region between two patches. Looking back into the E- and H-fields distributions for this wavelength, we can see that in the region between two patches, both fields have a moderate intensity, while in the region below the patch, the E-field has a quite

the proposed design. (g) Calculated absorption spectra for three different proposed designs and the solar irradiation spectrum in a range of 300-750 nm. (h) The calculated photocurrent values. The angular absorption response of the patch-based metasurface design for (i) TM and (j) TE polarizations

weak amplitude. That is why the light is mainly harvested in the spacing area. Similarly, for the longer wavelength resonance peak, the localization of the E-field in the region underneath the top nanoresonator will lead to the harvesting of the incident light in this area. The near unity light absorption in a thickness of approx. 15 nm could lead to a maximized collection efficiency. This efficiency could be further substantiated by the selective carrier's separation in Fe<sub>2</sub>O<sub>3</sub>-CdS interface. As Fig. 6f illustrates, upon the excitation of the metasurface design with solar irradiation, electron-hole pairs are generated inside the Fe<sub>2</sub>O<sub>3</sub> layer. The photoinduced holes are transferred into more energetically favorable valance band of CdS, and then they participate into water oxidation process. The electron conjugate will also move to ITO and from there into Fermi level of Ag to be collected in the external circuit. To quantitatively compare these three designs, we have calculated the photocurrent as a figure of merit for the photoactivity of the photoanode. We assumed that all of the photogenerated electron-hole pairs can contribute to the photocurrent before they recombine, which is a fair assumption when taking the above-mentioned statements into consideration. The photocurrents of these metasurfaces are calculated using:

$$J\left(mA/cm^{2}\right) = (e/hc) \int_{300 \ nm}^{750 \ nm} A(\lambda) I_{AM1.5} \lambda \, d\lambda \tag{5}$$

where J is the photocurrent density,  $I_{AM1,5}$  is the ASTM Air Mass 1.5 solar spectrum, and  $A(\lambda)$  is the spectral absorption calculated using Eq. 4. The calculated absorption spectra in a range of 300-750 nm have been exhibited in Fig. 6g. Using this data and the IAM1.5 spectrum, the photocurrent in each of these three cases has been found and plotted in the Fig. 6h. While the photocurrent is recorded to be 9.6  $mA/cm^2$  for the planar case, this value has been improved to 10.7 mA/cm<sup>2</sup> and 10.6 mA/cm<sup>2</sup> for grating and patch-guided mode design. These values are quite close to the theoretical maximum photocurrent value of 12.5 mA/cm<sup>2</sup> for a hematite-based photoanode. This has been acquired by the delicate design of the metasurface where the coupling of incident light into both cavity modes and guided mode resonances has been led in highly efficient light harvesting in a broad wavelength range below the band gap of the semiconductor. Finally, the angular response of the system has also been simulated to provide a comprehensive study on the proposed metasurface design. For this aim, the absorption profile of the patch-based cavity has been plotted for two different polarizations of TM and TE, as depicted in Fig. 6i-j. As we can see from these panels, the absorption response for TM polarization gets narrower as we go to wider excitation angles. In the meantime, the response for TE-polarized light stays almost intact in all incident angles. Considering the fact that, in TE polarization, the transverse component of E field does not change with the light angle of incidence, the Mie resonance excitation is supported in all oblique angles. Therefore, all of the obtained results prove that this  $MOSS_{g/p}$  is an efficient design for water-splitting application. Further improvement can be obtained by engineering the semiconductor-semiconductor and semiconductor-electrolyte interfaces using sub-nanometer ultrathin layers [93, 94]. Such ultrathin layers would not change the optical response of the design, while it significantly improves its electrical behavior.

### Conclusion

In this study, we proposed a design strategy based on semiconductor metasurfaces to maximize the light-matter interaction in dimensions much smaller than the wavelength and close to the hole diffusion length of a semiconductor. For this aim, we first found the limitations of a simple MS design using TMM modeling. Later, the impact of adding a nanostructured semiconductor-based grating on top of an MOS cavity design is explored. Our findings demonstrate that the proposed  $\text{MOSS}_{g/p}$  design can absorb light in a broad frequency range by the simultaneous excitation of cavity modes and Mie resonances. We showed that using a nanopatch design on top of the cavity design can lead to a polarization-insensitive absorption above 0.8 up to  $\lambda = 565$  nm. Moreover, our calculations estimated a watersplitting photocurrent of 10.6 mA cm<sup>-2</sup> that is quite close to the maximum achievable theoretical value of a hematite-based photoanode. The proposed design strategy is not only applicable for water-splitting application but also provides an elegant design route for the design of other highly efficient ultrathin optoelectronic devices.

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